EAST Search History

EAST Search History (Prior Art)

| Ref# | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|------|-------|--|---|---------------------|---------|---------------------|
| L1 | O | ("product\$3samesolaradjcells"). PN. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2010/10/15 10:16 |
| L2 | 28478 | product\$3 same solar adjc ells | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:16 |
| L3 | 9636 | product\$3 same solar adj cells | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:16 |
| L4 | 1 | L3 and establish\$3 adj correspondence same wafers same solar adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:18 |
| L5 | 3 | L3 and establish\$3 adj correspondence and wafers and solar adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:18 |
| L6 | 106 | crystallographic adj structure and wafer\$1 and solar adj cells | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:20 |
| L7 | 5 | L6 and matrix same solar adj cells | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:21 |
| L8 | 1 | L5 and solar adj cell and produced and treating and silicon adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:23 |
| _9 | 507 | solar adj cell and produced and treating and silicon adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:23 |

| L10 | 34 | matrix same solar adj cells and produced and treating and silicon adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:24 |
|-----|-------|--|---|----|----|---------------------|
| L11 | 2 | L10 and silicon adj wafer\$1 and cutt\$3 and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:26 |
| L12 | 0 | L11 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:26 |
| L13 | 5030 | solar adj cells and silicon adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:36 |
| L14 | 0 | solar adj cells and silicon adj wafer\$1 same solar adj cell adj traceability | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:36 |
| L15 | 1 | solar adj cells and silicon adj wafer\$1 and solar adj cell adj traceability | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:36 |
| L16 | 9636 | product\$3 same solar adj cells | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:38 |
| L17 | 8 | L16 and crystallographic adj structure and wafer\$1 and solar adj cells | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:39 |
| L18 | 18 | solar adj cells and silicon adj wafer\$1 and traceability | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:48 |
| L19 | 5 | L18 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:48 |
| L20 | 72405 | (compar\$3 or match\$3)and wafer\$1 and(solar adj cells or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:57 |

| L21 | 2509 | (compar\$3 or match\$3)same wafer\$1 same(solar adj cells cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:57 |
|-----|------|--|---|----|----|---------------------|
| L22 | 3 | L21 and matrix same solar adj cells and produced and treating and silicon adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:58 |
| _23 | 0 | L22 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/10/15 10:58 |
| S1 | 2124 | sheela chawan.Xa. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/09 15:40 |
| 32 | 2338 | sheela chawan.Xp. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/09 15:46 |
| 83 | 2 | St and wafer adj polishing | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/09 15:46 |
| S4 | 2 | S2 and wafer adj polishing | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/09 15:47 |
| S5 | 22 | S1 and wafer adj inspection | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/09 15:48 |
| S6 | 22 | S2 and wafer adj inspection | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/09 15:48 |
| S7 | 156 | wafer adj pad and inspection | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/09 16:05 |
| S8 | 156 | wafer adj pad and inspection | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:04 |

| S9 | 27 | S8 and notch | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:04 |
|-----|--------|---|---|----|----|---------------------|
| S10 | 337122 | crystallographic asj structure and wafer | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:09 |
| S11 | 966 | crystallographic adj structure and wafer | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:09 |
| S12 | 191 | crystallographic adj structure same wafer | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:09 |
| S13 | 150 | S12 and (@ad<"20040202" or @rlad<"20040202" or @prad<"20040202" or @ptad<"20040202") | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:21 |
| S14 | 117 | S12 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:21 |
| S15 | 16 | S14 and(solar adj cell or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:22 |
| S16 | 16 | \$15 and (compar\$3 or match\$3) and wafer and(solar adj cell or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:23 |
| S17 | 41 | crystallographic adj structure and wafer and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:39 |
| S18 | 5 | \$17 and(compar\$3 or match\$3) and wafer and(solar adj cell or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:40 |
| S19 | 4 | S18 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:40 |

| \$20 | 110 | (("(4352948") or ("6161054") or ("5203005") or ("5287472") or ("5287472") or ("5292677") or ("5289305") or ("5292677") or ("5489305") or ("4435488") or ("4435488") or ("4435489") or ("443693") or ("4599689") or ("5519736") or ("55265847") or ("5265847") or ("5265847") or ("5265847") or ("5315130") or ("5265864") or ("5315130") or ("536566") or ("539665") or ("55656392") or ("55656392") or ("55656392") or ("55656392") or ("55656392") or ("5592641") or ("5666392") or ("5606491") or ("6161213") or ("6225167") or ("6161213") or ("6225167") or ("6339819") or ("6140140") or ("61393819") or ("4353160") or ("4385180") or | US-PGPUB; USPAT; EPO; JPO; DEFWENT; IBM_TDB | OR . | OFF | 2010/03/10 16:43 |
|------|-----|---|---|------|-----|---------------------|
| S21 | 106 | ("4400868") or (").pn.")).PN. \$20 and(@ad<"20040202" or @rlad<"20040202" or @prad< "20040202" or @ptad<"20040202") | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB | OR | ON | 2010/03/10 16:43 |
| S22 | 106 | S20 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:43 |
| S23 | Ō | S22 and crystallographic adj structure and wafer and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:44 |
| S24 | Ō | S22 and crystallographic adj structure and wafer and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 16:46 |
| S25 | 5 | S22 and inspect\$3 and (crystallographic adj structure or wafer or ingot or cells or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:05 |
| 526 | 4 | \$25 and(compar\$3 or match\$3) and(solar adj cell or cell crystallographic adj structure or wafer or ingot or cells or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB | OR | ON | 2010/03/10 17:06 |

| S27 | 4 | S26 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:07 |
|-----|---------|--|---|----|----|---------------------|
| S28 | 4742 | crystallographic adj structure | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:10 |
| S29 | 4328355 | (wafer\$1 or semiconductor or solar adj cell or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:11 |
| S30 | 98638 | S29 and inspect\$3 and(cells or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:20 |
| S31 | 153527 | 529 and inspect\$3 and(cells or cell or wafer or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:21 |
| S32 | 4742 | crystallographic adj structure | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:22 |
| S33 | 632 | S31 and S32 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:27 |
| S34 | 1 | S33 and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:28 |
| S35 | 3 | inspect\$3 and solar adj cell and matrix and convert\$3 and electricity and solar adj cell and treating and silicon adj wafers and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:32 |
| S36 | 2 | S35 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:33 |
| S37 | 1 | \$35 and (compar\$3 or match\$3) and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:39 |

| S38 | 1 | S32 and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:40 |
|-----|-----|---|---|----|----|---------------------|
| S39 | 17 | \$29 and (compar\$3 or match\$3) and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:40 |
| S40 | 3 | S39 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:41 |
| S41 | 1 | S39 and crystallographic adj structure | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:51 |
| S42 | 1 | S39 and crystallographic adj structure and wafer adj structure and manufactured adj cell and crystallographic adj image and information and sufficient adj establish and correspondence and cell and wafer | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:58 |
| S43 | 1 | S39 and crystallographic adj structure and wafer adj structure and manufactured adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:59 |
| S44 | 1 | crystallographic adj structure and wafer adj structure and manufactured adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 17:59 |
| S45 | 2 | S29 and crystallographic adj structure and manufactured adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:00 |
| S46 | 0 | 945 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:01 |
| S48 | 607 | S32 and inspect\$3 and(cells or cell or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:06 |

| S49 | 1 | S48 and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:06 |
|-----|-----|---|---|----|----|---------------------|
| S50 | 587 | S48 and(compar\$3 or match\$3) and (memory or cell or memory adj cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:07 |
| S51 | 1 | S48 and(compar\$3 or match\$3) same(memory or cell or memory adj cell)same wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:08 |
| S52 | 1 | S50 and crystallographic adj structure and wafer adj structure and manufactured adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:09 |
| S53 | 1 | S50 and wafer adj structure and manufactured adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:09 |
| S54 | 1 | S50 and manufactured adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:10 |
| S55 | 297 | 950 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:10 |
| S56 | 12 | S55 and(compar\$3 or match\$3) and wafer and(solar adj cell or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:11 |
| S57 | 13 | S55 and inspect\$3 and wafer\$1 and(cells or cell or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:12 |
| S58 | 0 | S55 and inspect\$3 adj wafer\$1 same(cells or cell or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:13 |
| S59 | 0 | S55 and inspect\$3 adj wafer\$1 and(cells or cell or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:13 |

| S60 | 3559 | \$28 and(wafer\$1 or semiconductor or solar adj cell or cell or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:14 |
|-----|------|---|---|----|----|---------------------|
| S61 | 2 | S60 and manufactured adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:14 |
| S62 | 0 | S61 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:14 |
| S63 | 2 | S32 and manufactured adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:15 |
| S64 | 1818 | S32 and(wafer\$1 or semiconductor or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:16 |
| S65 | 237 | S32 and(wafer\$1 or semiconductor or memory)and inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:16 |
| S66 | 119 | S65 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:16 |
| S67 | 12 | S66 and(compar\$3 or match\$3) and wafer and(solar adj cell or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:19 |
| S68 | 38 | \$32 and inspect\$3 and(compar \$3 or match\$3) and wafer and (solar adj cell or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:28 |
| S69 | 41 | \$32 and inspect\$3 and(compar \$3 or match\$3) and wafer and (solar adj cell or cell or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:29 |
| S70 | 13 | S69 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:29 |

| S71 | 85837 | analyz\$3 and(crystalline or crystallographic adj structure) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:35 |
|-----|-------|--|---|----|----|---------------------|
| S72 | 18 | S71 and manufactured adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:36 |
| S73 | *11 | \$72 and(wafer\$1 or semiconductor or memory)and inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:36 |
| S74 | 1 | inspect\$3 and photovoltaic adj area and manufactured and crystalline adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:43 |
| S75 | 0 | S74 and @ad< "20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:44 |
| S76 | 0 | S72 and(imaging or ccd or camera or CMOS or IR)and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:46 |
| S77 | 0 | S71 and(imaging or ccd or camera or CMOS or IR)and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:47 |
| S78 | 31037 | S71 and(imaging or cod or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:47 |
| S79 | 8 | S78 and manufactured adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:47 |
| S80 | 2 | S79 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:48 |
| S81 | 2106 | S78 and(wafer\$1 or semiconductor\$1 or IC or intergrated adj circuit) and inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:51 |

| S82 | 45 | S81 and(compar\$3 or match\$3) same(memory or cell or memory adj cell)same wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:52 |
|-----|--------|--|---|----|----|---------------------|
| S83 | 18 | S82 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 18:52 |
| S84 | 25 | S17 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 19:17 |
| S85 | 5 | S72 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 19:48 |
| S86 | 118795 | (wafer\$1 or semiconductor\$1 or IC or intergrated adj circuit) and inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 19:49 |
| S87 | 9 | S86 and(imaging or ccd or camera or CMOS or IR)and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 19:49 |
| S88 | 1 | S87 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 19:49 |
| S89 | 533 | crystallographic adj structure and(wafer or ingot)and section | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 20:15 |
| S90 | 161 | S89 and analyz\$3 and (crystalline or crystallographic adj structure) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 20:16 |
| S91 | 0 | S89 and analyz\$3 and (crystalline or crystallographic adj structure) same ignot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 20:16 |
| S92 | 0 | \$30 and(imaging or cod or camera or CMOS or IR)and wafer adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 20:17 |

| S93 | 120 | S90 and(imaging or ccd or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 20:17 |
|------|-----|---|---|----|----|---------------------|
| S94 | 48 | S93 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 20:22 |
| S95 | 0 | S93 and etching and texturisation | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 20:59 |
| S96 | 7 | (wafer\$1 or semiconductor\$1 or IC or intergrated adj circuit)and etching and texturisation and inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:00 |
| S97 | 2 | 996 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:00 |
| S98 | 0 | \$97 and(compar\$3 or match\$3) same(memory or cell or memory adj cell or die)same wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:01 |
| S99 | 0 | S97 and(compar\$3 or match\$3) and(memory or cell or memory adj cell or die)and wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:01 |
| S100 | 2 | S97 and(memory or cell or memory adj cell or die)and wafer \$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:01 |
| S101 | 161 | S89 and S90 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:05 |
| S102 | 0 | S101 and(wafer\$1 or semiconductor\$1 or IC or intergrated adj circuit)and etching and texturisation and inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:06 |
| S103 | O | S101 and etching and texturisation and inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:06 |

| S104 | o | S101 and etching and texturisation | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:07 |
|------|------|---|---|----|----|---------------------|
| S105 | 1 | S89 and etching and texturisation | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:07 |
| S106 | 20 | S89 and solar adj cell | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:08 |
| S107 | 8 | S106 and @ad< "20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:08 |
| S108 | 2468 | ingot and production adj process | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:10 |
| S109 | 523 | \$108 and wafer\$3 and production adj process | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:11 |
| S110 | 128 | S109 and cell and production adj process | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:11 |
| S111 | 1 | S110 and wafer adj position\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:12 |
| S112 | 75 | S110 and @ad< "20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:13 |
| S113 | 0 | S112 and cell adj inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:13 |
| S114 | 75 | S112 and(memory or cell or memory adj cell or die)and wafer \$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:14 |

| S115 | 0 | S114 and(imaging or ccd or camera or CMOS or IR)and wafer adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:14 |
|------|----|--|---|----|----|---------------------|
| S116 | 12 | S114 and(imaging or ccd or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:14 |
| S117 | 10 | S116 and(compar\$3 or match\$3) and(memory or cell or memory adj cell or die)and wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:15 |
| S118 | 10 | S117 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/10 21:15 |
| S119 | 93 | measur\$3 and polycrystalline adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:04 |
| S120 | 63 | photovoltaic adj devices and (slicing or dice\$3 or diced)and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:05 |
| S121 | 0 | defect adj characteriz\$3 and classificat\$3 and crystal adj growth and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:07 |
| S122 | 54 | defect and classificat\$3 and crystal adj growth and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:08 |
| S123 | 0 | (defects or grain adj boundaries) and processing adj wafer\$1 and classificat\$3 and crystal adj growth and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:09 |
| S124 | 75 | (defects or grain adj boundaries) and processing adj wafer\$1 and crystal adj growth and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:10 |
| S125 | 3 | S119 and S120 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:10 |

| S126 | 0 | S124 and S125 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:11 |
|------|----|---|---|----|----|---------------------|
| S127 | 0 | S125 and(defects or grain adj boundaries)and crystal adj growth and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:11 |
| S128 | 0 | S125 and(defects or grain adj boundaries) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:12 |
| S129 | 0 | S125 and defects and crystal adj growth and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:12 |
| S130 | 10 | S120 and(imaging or cod or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:15 |
| S131 | 3 | S130 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:16 |
| S132 | 0 | S120 and inspect\$3 adj defects and crystal adj growth and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:29 |
| S133 | 0 | S120 and inspect\$3 and defects and crystal adj growth and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:29 |
| S134 | 4 | S120 and inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:30 |
| S135 | 1 | S134 and(defects or grain adj boundaries) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:30 |
| S136 | 0 | S135 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:30 |

| S137 | 55 | S120 and(defects or variances or voids or defects or stacking adj faults or inclusions or impurities or grain or crystal adj boundaries) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:35 |
|------|----|--|---|----|----|---------------------|
| S138 | 1 | S137 and(imaging or ccd or camera or CMOS or IR)and surface adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:35 |
| S139 | 0 | S138 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:36 |
| S140 | 55 | S120 and S137 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:36 |
| S141 | 20 | S140 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:36 |
| S142 | 13 | S141 and(compar\$3 or match\$3) and(wafer or ingot or cells or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:44 |
| S143 | 11 | S141 and(compar\$3 or match\$3) same(wafer or ingot or cells or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:46 |
| S144 | 11 | S143 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:46 |
| S145 | o | S141 and(imaging or ccd or camera or CMOS or IR)and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:49 |
| S146 | О | S141 and(imaging or ccd or camera or CMOS or IR)and wafer adj image and cell adj image and(compar\$3 or match \$3) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:50 |
| S147 | О | \$137 and(imaging or ccd or camera or CMOS or IR)and wafer adj image and cell adj image and(compar\$3 or match \$3) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:50 |

| S148 | O | S120 and(imaging or ccd or carnera or CMOS or IR)and wafer adj image and cell adj image and(compar\$3 or match \$3) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:51 |
|------|----|--|---|----|----|---------------------|
| S149 | 0 | S120 and(imaging or ccd or carnera or CM/OS or IR)and wafer adj image and cell adj image and(compar\$3 or match \$3)and surface adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:51 |
| S150 | 0 | \$119 and(imaging or ccd or camera or CMOS or IR)and wafer adj image and cell adj image and(compar\$3 or match \$3)and surface adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:52 |
| S151 | 0 | S124 and (imaging or ccd or camera or CMOS or IR) and wafer adj image and cell adj image and (compar\$3 or match \$3) and surface adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:52 |
| S152 | O | S120 and(imaging or ccd or camera or CMOS or IR)and (compar\$3 or match\$3)and surface adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:53 |
| S153 | 5 | (imaging or ccd or camera or CMOS or IR) and(compar\$3 or match\$3) and photovoltaic adj devices and(slicing or dice\$3 or diced) and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:54 |
| S154 | 2 | S153 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:54 |
| S155 | 2 | S154 and(defects or variances or voids or defects or stacking adj faults or inclusions or impurities or grain or crystal adj boundaries) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 10:55 |
| S156 | 4 | \$120 and(wafer\$1 or semiconductor\$1 or IC or intergrated adj circuit) and inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:04 |
| S157 | 10 | S119 and(wafer\$1 or semiconductor\$1 or IC or intergrated adj circuit) and inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:04 |
| S158 | O | S156 and(imaging or ccd or carnera or CM/CS or IR)and wafer adj image and cell adj image and(compar\$3 or match \$3)and surface adj wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:04 |

| S159 | 0 | S156 and(imaging or ccd or camera or CMOS or IR) and wafer adj image and cell adj image and(compar\$3 or match \$3) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:05 |
|------|---|--|---|----|----|---------------------|
| S160 | 0 | S157 and(imaging or ccd or camera or CMOS or IR)and wafer adj image and cell adj image and(compar\$3 or match \$3) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:05 |
| S161 | 0 | \$157 and(imaging or cod or camera or CMOS or IR)and (compar\$3 or match\$3)and photovoltaic adj devices and (slicing or dice\$3 or diced)and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:05 |
| S162 | 0 | S157 and(imaging or ccd or camera or CMOS or IP)and (compar\$3 or match\$3)and (cell adj solar or cell or memory or wafer\$1) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:06 |
| S163 | 4 | S157 and(imaging or cod or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:06 |
| S164 | 4 | S163 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:06 |
| S165 | 1 | S164 and(defects or variances or voids or defects or stacking adj faults or inclusions or impurities or grain or crystal adj boundaries) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:07 |
| S166 | O | S119 and produc\$4 and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:16 |
| S167 | 0 | S120 and produc\$4 and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:16 |
| S168 | 0 | S122 and produc\$4 and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:16 |
| S169 | 0 | S122 and(produc\$4 or obtaining) and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:16 |

| S170 | 0 | S157 and(produc\$4 or obtaining) and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:17 |
|------|------|---|---|----|----|---------------------|
| S171 | 0 | S153 and(produc\$4 or obtaining) and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:17 |
| S172 | 0 | S155 and(produc\$4 or obtaining) and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:17 |
| S173 | 1 | crystallographic adj structure and(produc\$4 or obtaining)and wafer adj image and cell adj image and wafer | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:18 |
| S174 | 1 | crystallographic adj structure and(produc\$4 or obtaining)and wafer adj image and(cell adj image or cells or cell or wafer or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:20 |
| S175 | 3130 | crystallographic adj structure and(produc\$4 or obtaining)and (cell adj image or cells or cell or wafer or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:20 |
| S176 | 2 | \$175 and photovoltaic adj devices and(slicing or dice\$3 or diced) and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:21 |
| S177 | 2 | S176 and @ad< "20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:21 |
| S178 | 0 | S177 and(imaging or ccd or camera or CMOS or IR or image) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:31 |
| S179 | 1586 | S175 and(imaging or ccd or camera or CMOS or IR or image) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:31 |
| S180 | o | \$179 and photovoltaic adj devices and(slicing or dice\$3 or diced)and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:32 |

| S181 | 0 | \$179 and photovoltaic adj devices and(slicing or dice\$3 or diced) and (ingot or wafer\$1 or semiconductor\$1 or IC or intergrated adj circuit) and inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:33 |
|------|-----|--|---|----|----|---------------------|
| S182 | 2 | \$175 and photovoltaic adj devices and(slicing or dice\$3 or diced)and (ingot or wafer\$1 or semiconductor\$1 or IC or intergrated adj circuit) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:34 |
| S183 | 2 | S182 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:34 |
| S184 | 2 | \$183 and(defects or variances or voids or defects or stacking adj faults or inclusions or impurities or grain or crystal adj boundaries or grain adj boundaries) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/11 11:37 |
| S185 | 850 | wafer\$1 adj identification | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:14 |
| S186 | 1 | S185 and etching and texturisation | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:14 |
| S187 | 348 | S185 and (etching or texturisation) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:15 |
| S188 | 48 | wafer\$1 adj identification same (imaging or ccd or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:16 |
| S189 | 12 | S188 and (etching or texturisation) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:16 |
| S190 | O | S189 and phosphorus adj doping | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB | OR | ON | 2010/03/12 12:16 |

| S191 | 0 | S189 and phosphorus and doping | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:17 |
|------|------|--|---|----|----|---------------------|
| S192 | 8 | \$189 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:17 |
| S193 | 0 | S188 and phosphorus adj doping | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:21 |
| S194 | 1323 | phosphorus adj doping | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:21 |
| S195 | 872 | S194 and (etching or texturisation) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:21 |
| S196 | 1 | S195 and wafer\$1 adj identification and(imaging or ccd or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:21 |
| S197 | 29 | S195 and identification and (imaging or cod or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:23 |
| S198 | 16 | S197 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:23 |
| S199 | 0 | S198 and edge adj etching | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:23 |
| S200 | 14 | S198 and edge and etching | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:23 |
| S201 | 0 | S200 and oxide adj removal | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:24 |

| S202 | 10 | \$200 and oxide and removal | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:24 |
|--------------|------|---|---|----|----|---------------------|
| S203 | 1323 | phosphorus adj doping | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:25 |
| S204 | 898 | S203 and @ad< "20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:25 |
| S2 05 | 8 | S204 and oxide adj removal | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:26 |
| S206 | 0 | S205 and antireflective adj coating | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:26 |
| S207 | 0 | S205 and screen adj print | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:27 |
| S208 | 1 | \$203 and inspect\$3 adj wafer\$1 and(cells or cell or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:28 |
| S209 | 1 | \$203 and wafer\$1 adj Identification and(imaging or ccd or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:29 |
| S210 | 566 | wafer\$1 and screen adj print | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:29 |
| S211 | 15 | S210 and antireflective adj coating | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:30 |
| S212 | 2 | S211 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:30 |

| S213 | 0 | S198 and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:34 |
|------|----|--|---|----|----|---------------------|
| S214 | 1 | S203 and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:34 |
| S215 | 1 | determining adj quality and wafer adj production and cell adj production and process | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:36 |
| S216 | 12 | quality and wafer adj production and cell adj production and process | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:37 |
| S217 | 1 | S216 and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:37 |
| S218 | 2 | S216 and identification and (Imaging or ccd or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:37 |
| S219 | 0 | S218 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:38 |
| S220 | 8 | S216 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/12 12:40 |
| S221 | 22 | Ingot adj production and wafer adj production | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 11:52 |
| S222 | 10 | S221 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 11:53 |
| S223 | 0 | Ingot adj production and wafer adj production same(slicing or dice\$3 or diced) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 12:07 |

| S224 | 6 | Ingot adj production same (slicing or dice\$3 or diced) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 12:07 |
|------|-----|---|---|----|----|---------------------|
| S225 | 4 | S224 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 12:07 |
| S226 | 0 | S224 and cell adj inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 12:12 |
| S227 | 1 | S221 and cell adj inspect\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 12:12 |
| S228 | 0 | cell adj inspect\$3 and wafer adj production same(slicing or dice \$3 or diced) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 12:14 |
| S229 | 0 | cell adj inspect\$3 and wafer adj production and(slicing or dice\$3 or diced) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 12:14 |
| S230 | 22 | cell adj inspect\$3 and(slicing or dice\$3 or diced) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 12:14 |
| S231 | 6 | \$230 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 12:18 |
| S232 | О | cell adj inspect\$3 and imageing and(slicing or dice\$3 or diced) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 13:05 |
| S233 | 140 | image\$3 and cell adj image and (slicing or dice\$3 or diced) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 13:06 |
| S234 | 0 | \$233 and Ingot adj production same(slicing or dice\$3 or diced) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 13:06 |

| S235 | 0 | \$233 and Ingot adj production and(slicing or dice\$3 or diced) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 13:07 |
|------|----|--|---|----|----|---------------------|
| S236 | 2 | "6140140".pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/16 14:52 |
| S237 | 23 | cell adj inspect\$3 and(slicing or dice\$3 or diced) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:19 |
| S238 | 6 | S237 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:19 |
| S239 | 3 | S238 and (breakage or damage) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:21 |
| S240 | 64 | photovoltaic adj devices and (slicing or dice\$3 or diced)and ingot | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:23 |
| S241 | 55 | S240 and(defects or variances or voids or defects or stacking adj faults or inclusions or impurities or grain or crystal adj boundaries) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:23 |
| S242 | 20 | S241 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:24 |
| S243 | 3 | S242 and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:25 |
| S244 | 2 | S237 and(compar\$3 or match\$3) and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:36 |
| S245 | 1 | S244 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:37 |

| S246 | 4764 | crystallographic adj structure | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:37 |
|------|------|--|---|----|----|---------------------|
| S247 | 110 | \$246 and(compar\$3 or match\$3) and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:37 |
| S248 | 65 | S247 and @ad< "20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:38 |
| S249 | 2 | 7144457".pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:44 |
| S250 | 0 | \$249 and(compar\$3 or match\$3) and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:44 |
| S251 | 0 | S249 and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:44 |
| S252 | 2 | "6465781".pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:45 |
| S253 | 0 | S252 and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:45 |
| S254 | 4764 | crystallographic adj structure | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:46 |
| S255 | 1 | S254 and wafer adj image and cell adj image | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:46 |

| \$256 | 110 | (("(4352948") or ("6161054") or ("5200050") or ("5287472") or ("5292677") or ("52472") or ("5292677") or ("5485097") or ("6243308") or ("4445498") or ("4445498") or ("44519035") or ("44593835") or ("4598935") or ("4598983") or ("55024972") or ("6404072") or ("6404072") or ("6404072") or ("6404072") or ("4353160") or ("4300221") or ("4300221") or ("44000221") or ("4400221") or ("4 | US-PGPUB; USPAT; EPO; JPO; JPO; DEFWENT; IBM_TDB | OR . | OFF | 2010/03/27 17:47 |
|-------|-----|--|---|------|-----|---------------------|
| S257 | 106 | S256 and @ad< "20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:47 |
| S258 | 5 | \$257 and inspect\$3 and (crystallographic adj structure or wafer or ingot or cells or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:47 |
| S259 | 4 | \$258 and(compar\$3 or match\$3) and(solar adj cell or cell crystallographic adj structure or wafer or ingot or cells or cell) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:47 |
| S260 | 5 | \$257 and inspect\$3 and (crystallographic adj structure or wafer or ingot or cells) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:47 |
| S261 | 0 | \$260 and(compar\$3 or match\$3) and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:48 |
| S262 | 0 | S260 and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:48 |

| S263 | 142 | image\$3 and cell adj image and (slicing or dice\$3 or diced) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:48 |
|------|-----|---|---|----|----|---------------------|
| S264 | 6 | S263 and(compar\$3 or match\$3) and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:48 |
| S265 | 2 | S264 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:49 |
| S266 | 110 | S246 and(compar\$3 or match\$3) and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:50 |
| S267 | 65 | \$266 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:50 |
| S268 | 66 | \$267 cell adj image and wafer adj image and(compar\$3 or match\$3) and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:51 |
| S269 | 66 | \$267 cell adj image and wafer adj image same(compar\$3 or match\$3)same breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:51 |
| S270 | 65 | S269 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:51 |
| S271 | 2 | "5667597".pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:55 |
| S272 | 0 | S271 and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:55 |
| S273 | 2 | "6316832".pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:56 |

| S274 | 2 | S273 and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:56 |
|-------|------|---|---|----|----|---------------------|
| S275 | 4764 | S254 cell adj image and wafer adj image and(compar\$3 or match\$3) and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:57 |
| S276 | 1 | \$254 and cell adj image and wafer adj image and(compar\$3 or match\$3)and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:58 |
| S277 | 2 | "5716459".pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:58 |
| S278 | 0 | S277 and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:59 |
| \$279 | 2 | "5153444".pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:59 |
| S280 | O | S279 and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 17:59 |
| S281 | 535 | crystallographic adj structure and(wafer or ingot)and section | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:01 |
| S282 | 1 | \$281 and cell adj image same wafer adj image same(compar \$3 or match\$3)same breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:01 |
| S283 | 2 | "7144457".pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:02 |
| S284 | О | S283 and(breakage or damaged) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:03 |

| S285 | 42 | \$254 and inspect\$3 and(compar \$3 or match\$3)and wafer and (solar adj cell or cell or memory) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:08 |
|------|------|---|---|----|----|---------------------|
| S286 | 13 | \$285 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:08 |
| S287 | 0 | S286 and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:08 |
| S288 | 535 | crystallographic adj structure and(wafer or ingot)and section | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:09 |
| S289 | 162 | S288 and analyz\$3 and (crystalline or crystallographic adj structure) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:09 |
| S290 | 120 | S289 and(imaging or ccd or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:09 |
| S291 | 48 | \$290 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:09 |
| S292 | o | S291 and(breakage or damaged) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:09 |
| S293 | 2491 | ingot and production adj process | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:11 |
| S294 | 525 | S293 and wafer\$3 and production adj process | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:11 |
| S295 | 128 | S294 and cell and production adj process | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:11 |

| S296 | 75 | S295 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:11 |
|-------|----|---|---|----|----|---------------------|
| S297 | 75 | S296 and(memory or cell or memory adj cell or die)and wafer \$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:11 |
| S298 | 12 | S297 and(limaging or ccd or camera or CMOS or IR) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:11 |
| \$299 | 10 | S298 and(compar\$3 or match\$3) and(memory or cell or memory adj cell or die)and wafer\$1 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:11 |
| S300 | 10 | S299 and @ad<"20040202" | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:11 |
| S301 | 6 | S300 and(breakage or damaged) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:11 |
| S302 | 2 | S300 and breakage | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:17 |
| S303 | 2 | "6140140".pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:31 |
| S304 | 1 | S303 and memory | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 18:32 |
| S305 | 2 | "5757474" .pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 21:51 |
| S306 | 0 | S305 and(breakage or damage) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/27 21:56 |

| \$307 | 2 | "5757474".pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/29 10:00 |
|-------|-----|---|--|------|-----|---------------------|
| S308 | 2 | "6482661".pn. | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2010/03/29 10:01 |
| S309 | 111 | [("(4352948") or ("6161054") or ("5203005") or ("5287472") or ("528077") or ("5282677") or ("5282677") or ("5282677") or ("5282677") or ("5282677") or ("5282677") or ("4354985") or ("4471483") or ("4490055") or ("4519035") or ("4598983") or ("4596887") or ("5596867") or ("5596947") or ("5567284") or ("55619419") or ("5567284") or ("55619419") or ("5569845") or ("5598459") or ("5598459") or ("5698459") or ("5698459") or ("5698459") or ("659849") or ("6161213") or ("6225167") or ("6161213") or ("6225167") or ("6340869") or ("64400912") or ("4306461") or ("4306461") or ("4306861") | US-PAT; EPO; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR . | OFF | 2010/03/29 |

10/15/10 11:00:02 AM

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